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**INFORMATION DISCLOSURE
STATEMENT BY APPLICANT**

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Sheet 1 of 1

Complete if Known

Application Number	Based on PCT/JP2004/003617
Confirmation Number	Unknown
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First Named Inventor	Hiroyuki AKAGAWA
Art Unit	Unknown
Examiner Name	Unknown
Attorney Docket Number	Q90414

U.S. PATENT DOCUMENTS

Examiner Initials*	Cite No. ¹	Document Number		Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document
		Number	Kind Code ² (if known)		
		US			
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FOREIGN PATENT DOCUMENTS

Examiner Initials*	Cite No. ¹	Foreign Patent Document			Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Translation ⁴
		Country Code ³	Number ¹	Kind Code ² (if known)			
/S.F./		JP	2003-51472	A	02-21-2003	SHINETSU CHEMICAL CO	Abstract
		JP	2002-162726	A	06-07-2002	HOYA CORP.	Abstract
		JP	2004-54285	A	02-19-2004	HOYA CORP.	Abstract
		JP	2004-29735	A	01-29-2004	HOYA CORP.	Abstract
		JP	64-40267	A	02-10-1989	SHINETSU CHEMICAL CO., NAOETSU SEIMITSU KAKO KK	Abstract
		JP	2002-318450	A	10-31-2002	SHINETSU CHEMICAL CO	Abstract

NON PATENT LITERATURE DOCUMENTS

Examiner Initials*	Cite No. ¹	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city, and/or country where published.	Translation ⁴
/S.F./		MASAMITSU ITOH, et al., New Concept of Specification for Mask Flatness, Proceedings of SPIE Photomask and Next-Generation Lithography Mask Technology IX, SPIE Vol. 4754 (2002), 43-53	

Examiner Signature	/Stewart Fraser/	Date Considered	09/23/2008
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